

Model 6500 Automatic, High Accuracy Die Attach System

The MAT Model 6500 Die Attach System performs Face Up and Flip Chip applications based on Epoxy, Eutectic, C2/C4, Ultrasonic, ACF/ACP, Silver Glass, UV Adhesives, Ag Sintering, etc.

All process capabilities are built-in and can be switched from one to another by simply enabling or disabling a parameter. The **Versatile** and **User-Friendly** Graphic User Interface running under Windows® allows switching processes within seconds.

All hardware required for the above applications is plug & play. Model 6500 is a **fully automatic** system yet having a large work area and optionally manual material load/unload for easy operation.

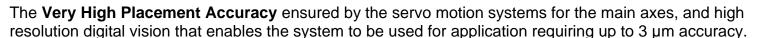
For **Multi-Chip Modules**, **RF**, **Hybrid** applications the machine handles components as small as 150 μ m, up to practically any size presented in various forms:

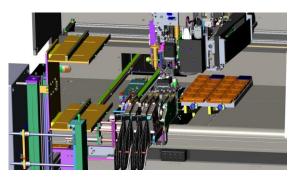
- Up to 40 Waffle/Gel packs
- Up to 8 Tape & Reel feeders
- 300 mm Wafers.

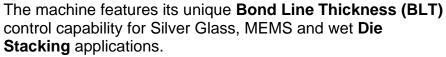
The Thermal or UV adhesive is applied by:

- Volumetric, Time-Pressure or Jet Dispenser in complex shapes from a library
- Stamping (Pin Transfer) down to 75 µm adhesive dot diameter.

The Automatic Tool Replacement Station handles up to 12 different flat face pickup tools, pyramidal die collets and stamping tools.







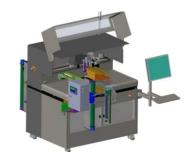
- Programmable BLT
- BLT control by Height Measurement
- Programmable Bond Force and Touchdown Velocity
- Very high BLT accuracy independent of the adhesive volume variation.
- Better than 5 µm BLT accuracy.





Model 6500 Die Attach System

Unmatched Versatility

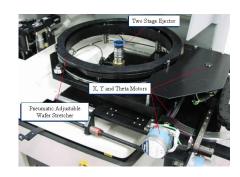


Full **Flip Chip** process capability including chip flipping, bump fluxing and chip accurate alignment over a high resolution Up Looking Camera. The machine performs cold and heated processes including:

- C2, C4 or similar cold process or heated process for pre-tacking
- Gold to Gold Interconnect (GGI) using Thermo-Sonic process at up to 130 KHz frequency and up to 40 Watt power.
- Thermo-Compression up to 90 N and 500°C
- Underfill for all above assemblies.

The unique two stage die ejection system from diced wafers enables picking large and very thin dice from blue or UV tapes:

- Up to 300 mm wafers
- Built-in tape stretching system
- Thin die capability down to 50 μm
- Die sizes from 150 µm to over 50 mm.
- Unusual die aspect ratio capability
- Electronic wafer map and/or lnk dot detection.





Heated applications up to 500°C for different **Eutectic** processes including AuSn, AuGe, AuSi and other interconnection materials.

- Capability to perform Eutectic MCM applications thanks to the unique local heating of the die.
- Picks components from Gel packs, wafers or waffle packs at room temperature.
- Programmed tool heating time and fast cool down. Hot forming gas provision during the reflow process.
- Scrubbing with programmable shape, amplitude and velocity.
- Substrate preheating and gas cover.
- Uses pyramidal die collets for the chips and flat face pickup tools for the preforms.

Specification Highlights

Work Area: up to 20" x 12".

Die size range: 0.006" to over 2"

Die Material: GaAs, Si, Glass, etc.

Substrates: Lead Frames, Ceramic, Silicon

Wafers, PCB's, Metal, TO cans, etc. Pickup/Bond Force: 40 to 9,000 grams.

Deep Access: 50 mm Z Travel.

Placement Accuracy: better than ±3 μm - application

dependent.

Throughput: up to 1000 CPH - application dependent.

Size: 1.2 Sq. Meter. Weight: 350 Kg.

